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(54) HIGH-DENSITY PLASMA FOR IONIZED METAL DEPOSITION CAPABLE OF **EXCITING A PLASMA WAVE**

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patent is extended or adjusted under 35

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Related U.S. Application Data

(63) Continuation-in-part of application No. 09/373,097, filed on Aug. 12, 1999, now Pat. No. 6,183,614, which is a continuation-in-part of application No. 09/249,468, filed on Feb. 12,

| (51) | Int. Cl. ⁷ | C23C | 14/34 |
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- (52) U.S. Cl. 204/192.12; 204/298.2
- 204/298.22, 192.12

References Cited (56)

U.S. PATENT DOCUMENTS

| 4,444,643 | * | 4/1984 | Garrett | 204/298.2 |
|-----------|---|---------|---------------|-----------|
| 5,252,758 | | 10/1993 | Demaray et al | 204/298.2 |
| 5,770,025 | | 6/1998 | Kiyota | 204/298.2 |
| 5,897,752 | * | 4/1999 | Hong et al | 204/298.2 |
| 5,966,607 | * | 10/1999 | Chee et al | 438/305 |

FOREIGN PATENT DOCUMENTS

| 06-620583A | | 10/1994 | (EP) | |
|--------------|---|---------|------|----------------|
| 0 691 419 A1 | * | 1/1996 | (EP) | 204/298.19 |

| 2 241 710 | * | 9/1991 | (GB) | 204/298.19 |
|-----------|---|---------|--------|----------------|
| 62-89864 | | 4/1987 | (JP) . | |
| 63-282263 | | 11/1988 | (JP) . | |
| 11-074225 | | 3/1999 | (JP) . | |

OTHER PUBLICATIONS

- B. Window et al. "Charged particle fluxes from planar magnetron sources", J. Vac. Sci. Technol. A 4(2), Mar./Apr. 1986, pp. 196-202.*
- J. Musil, et al. "Unbalanced magnetrons and new sputtering systems with enhanced plasma ionization", J. Vac. Sci. Technol. A 9(3), May/Jun. 1991, pp. 1171-1177.*
- W. Munz "The unbalanced magnetron: current status of development", Surface and Coatings Technology, 48 (1991), pp. 81–94.*

Matsuoka et al., "Dense plasma production and film deposition by new high-rate sputtering using an electric mirror," Journal of Vacuum Science and Technology A, vol. 7, No. 4, Jul./Aug. 1989, pp. 2652-2657.

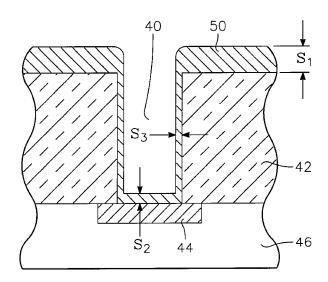
* cited by examiner

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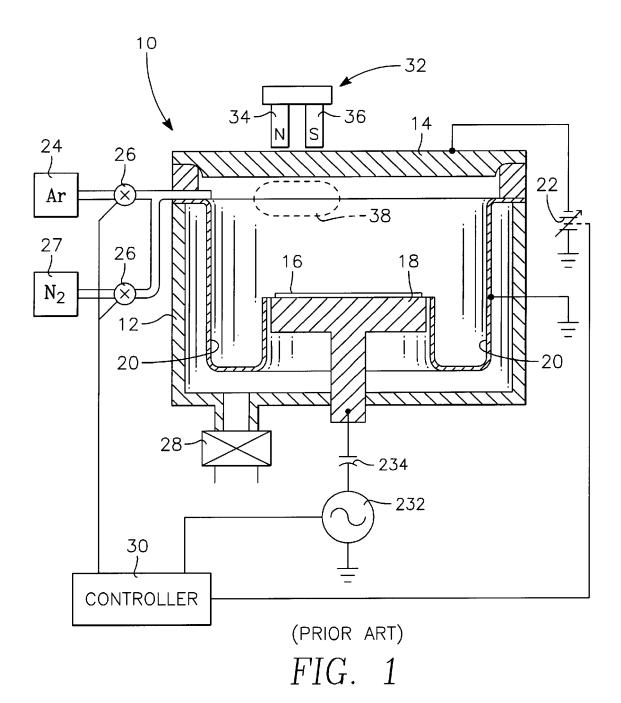
(57)**ABSTRACT**

A magnetron especially advantageous for low-pressure plasma sputtering or sustained self-sputtering having reduced area but full target coverage. The magnetron includes an outer pole face surrounding an inner pole face with a gap therebetween. The outer pole of the magnetron of the invention is smaller than that of a circular magnetron similarly extending from the center to the periphery of the target. A preferred triangular shape having a small apex angle of 20 to 30° may be formed from outer bar magnets of one magnetic polarity enclosing an inner magnet of the other magnetic polarity. The magnetron allows the generation of plasma waves in the neighborhood of 22 MHz which interact with the 1 to 20 eV electrons of the plasma to thereby increase the plasma density.

22 Claims, 11 Drawing Sheets







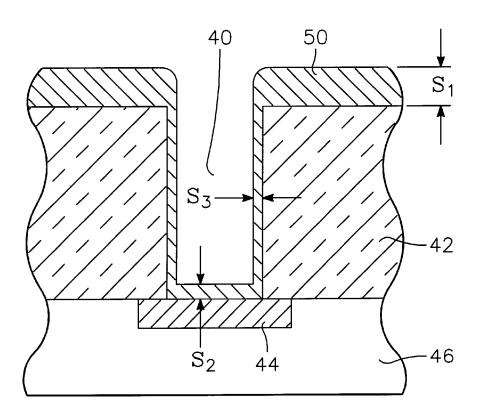
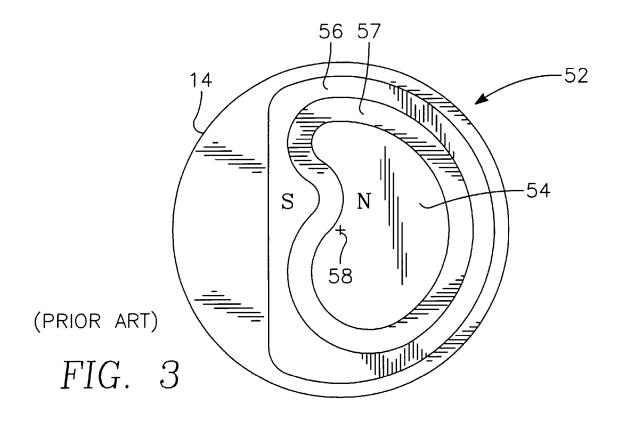
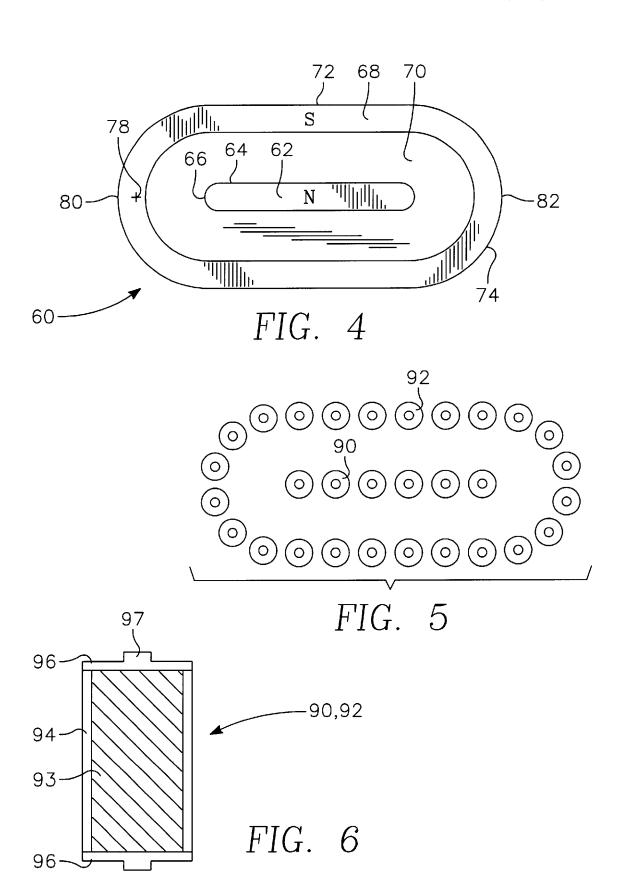
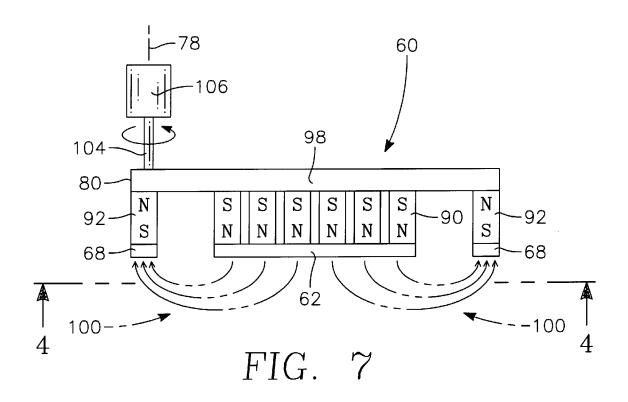


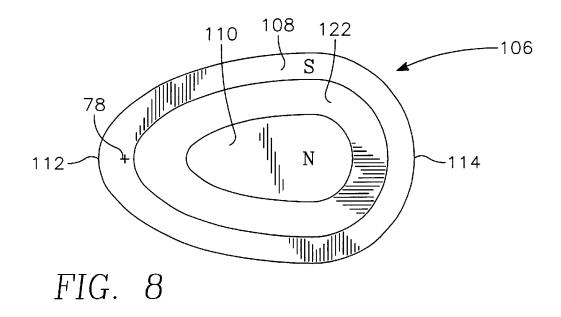
FIG. 2













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